



Response under 37 C.F.R. §1.116
Expedited Procedure
Group Art Unit 1712

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

KOZAWA et al.

Attorney Docket No: 100021-00065

Application No. 10/005,347

Art Unit: 1712

Filed: December 7, 2001

Examiner: K. Peng

For: SILICON-CONTAINING POLYMER, PROCESS FOR ITS PRODUCTION,
RESIST COMPOSITION EMPLOYING IT, PATTERN-FORMING METHOD AND
ELECTRONIC DEVICE FABRICATION METHOD

AMENDMENT AND RESPONSE UNDER 37 C.F.R. § 1.116

Mail Box AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

December 20, 2005

Sir:

This paper is filed in response to the final Office Action dated October 12, 2005, in connection with the above-identified application. Applicants respectfully request reconsideration and withdrawal of the rejections in view of the following amendments and remarks.

Amendment to the claims begin at page 2.

The Remarks begin at page 4.